An Example Abstract for the International Conference on Electron, Ion, and Photon Beam Technology and Nanofabrication

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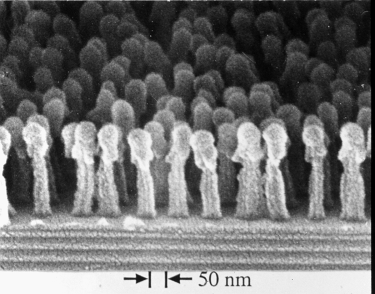
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*Figure 1: The Debutantes' Ball:* At the debutantes' ball, young nano-women gather in their finery at the edge of the stage to weep because none of the nano-boys will dance with them. The micrograph shows an array of 50 nm wide posts with a periodicity of 100 nm. The posts consist of PMMA on top of an antireflection coating. The substrate consists of a 250 nm thick layer of silicon nitride on silicon. Winner of the 1995 “Most Bizarre Micrograph” prize. Submitted by Tim Savas, Massachusetts Institute of Technology.

1. References should follow standard APS style guidelines. For more, see http://publish.aps.org/STYLE/ms.html [↑](#footnote-ref-1)